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Phosphorus, Sulfur, and Silicon and the Related Elements

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Phosphorus, Sulfur, and Silicon and the Related Elements

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Phosphorus, Sulfur, and Silicon and the Related Elements welcomes submissions involving the organic, inorganic, and biochemistry of phosphorus (including arsenic, antimony, and bismuth), sulfur (including selenium and tellurium), and silicon (including germanium and tin). In addition to research describing new chemistry of a particular element, especially welcome are presentations emphasizing relationships between elements and families of elements: for example, research comparing synthetic, mechanistic, or structural features providing new insight leading to a more rapid advance of science in these areas.

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